

***Chip-scale* Photonics**



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Microsystems Technology Symposium

March 5, 2007

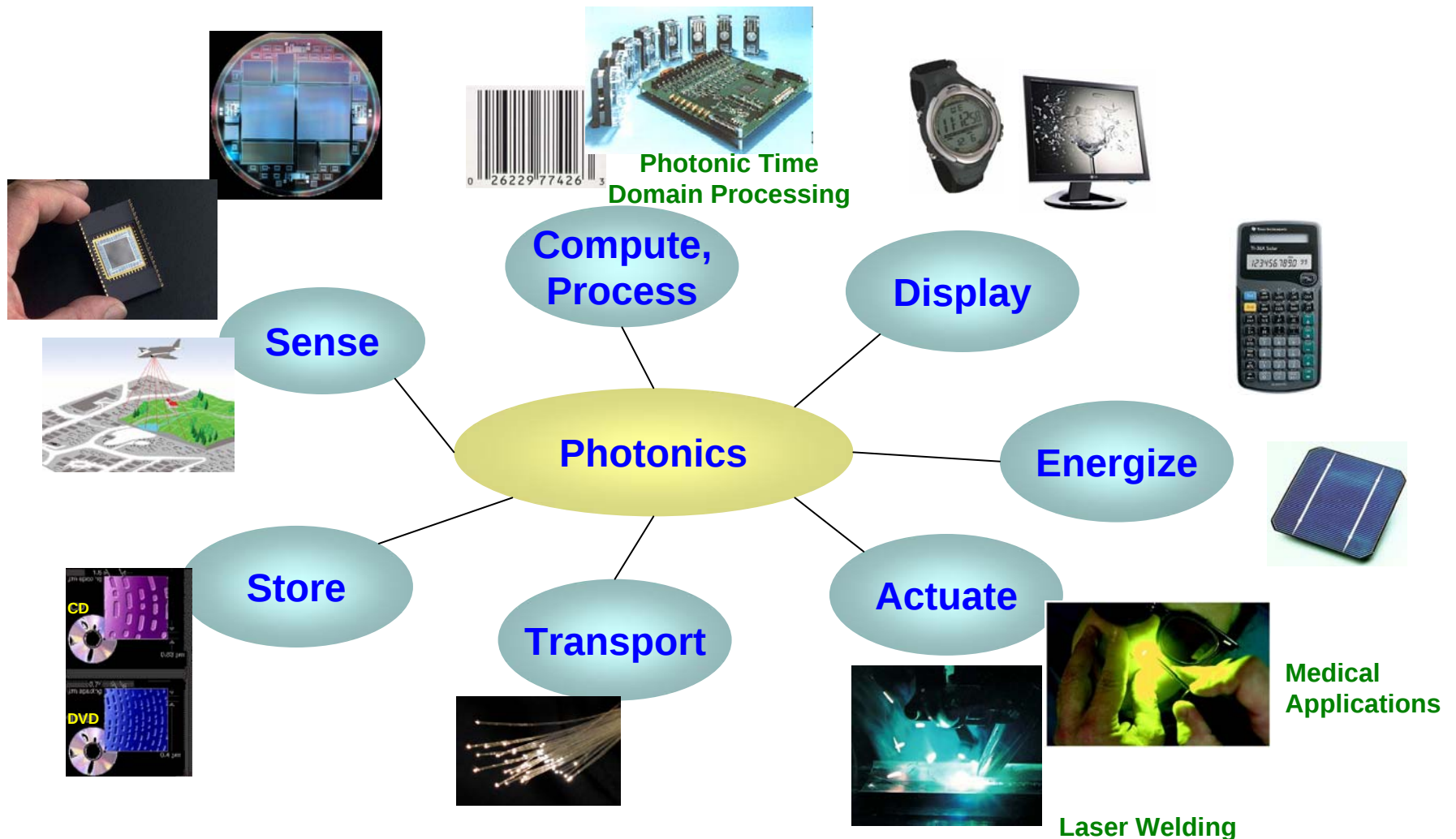
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Photonic information/energy processing



What do we do now with photons?





Photonics at the Chip level



Many functions require complex circuits structures that may benefit from *chip-scale* fabrication techniques.

- Exploit benefits of precise material growth techniques
- Achieve maximum performance, yield, and circuit complexity
- Combine multiple functions on single chip
- Provide means to “get close” to Silicon
- Leverage advantages of lithographic design and fabrication for SCALABILITY in future generations

But

- Make sure advantages are real
 - Use solid metrics to connect technology and system parameters
- Compete with, or “help,” Silicon with great trepidation!

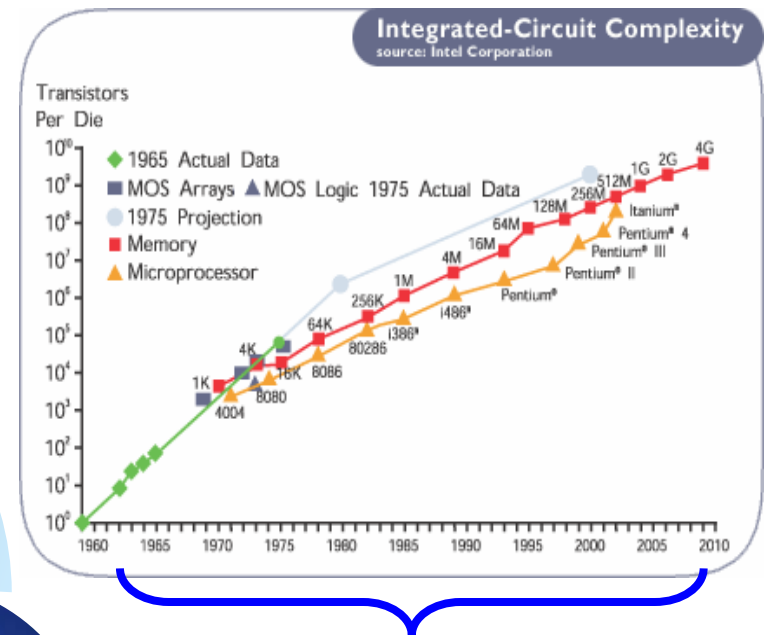
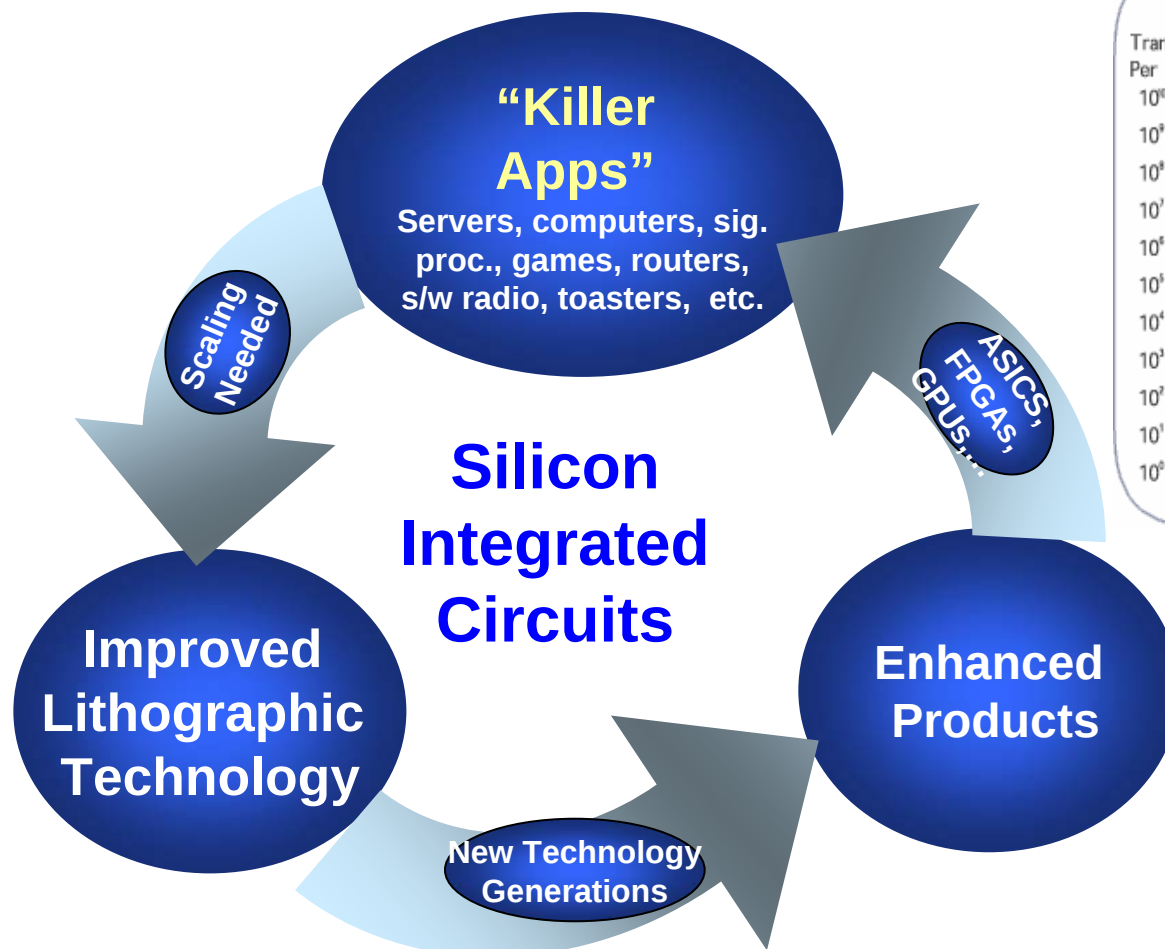


The vicious (but lucrative) cycle of Si scaling



Lithography opened path to Scaling:

- Sustained value-added cycle due to IP that is magnified by use of technology platform



~45 years of exponential scaling!



Photonics' "tentative" start at chip-scale scaling





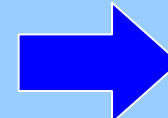
Litographic Scaling in Photonics



Intellectual Property
(Circuit Design)



Scaling



Drives
Technology

So....Will Photonics have an IC-driven scaling pathway?

- Can we leverage the telecom investment and focus on chip-scale applications to drive technology?
- Which Integrated Photonics platforms will emerge?
- How close to the photonic “information density” limits can we get?

AND... Can we go...



???

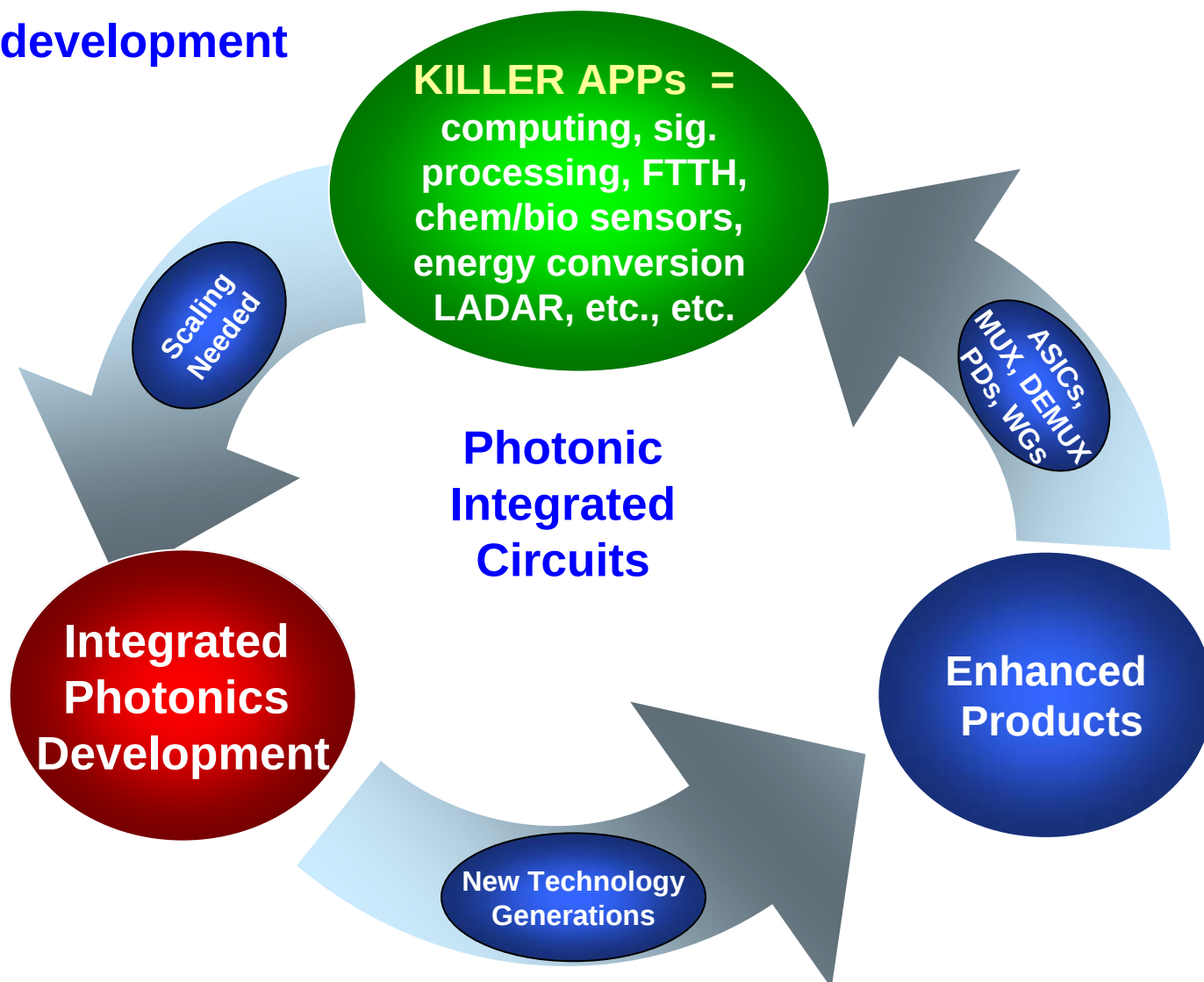
- Analog optical signal processing – that is **scalable** and **programmable**.
- Optical interconnects – to **enable** Silicon scaling
- Optical digital computing – as **complement** to Silicon
- Computational Sensing – but with **integrated flat form-factor** optics.



Approach: Enrich the “Killer App” domain



... to spur PIC development



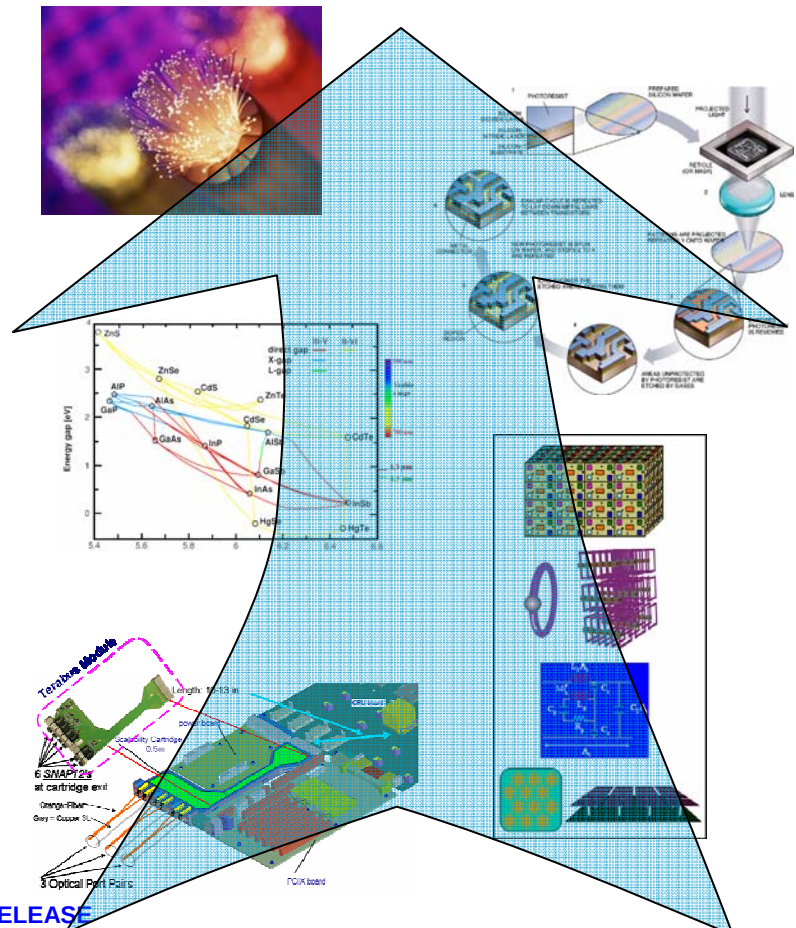
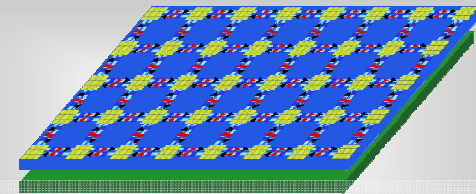


Photonics Value Proposition



How do we get there?

- Leverage **3 decades+** of FO technology and related devices (e.g. non-linear optics), but for non-transport functions
- Leverage **4 decades+** of lithography-based chip technology
 - What are the PIC technology platforms?
- Expand **5 decades+** of band-gap engineering
- Employ “Magic Meta-Materials” based on photonic/ phononic/ electronic/ plasmonic engineered materials
- Exploit a PIC’s natural match at interface to outside (photonic) world





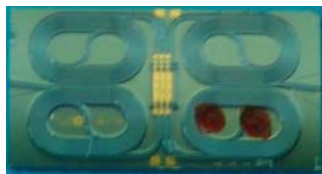
PICs enable the future



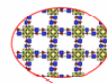
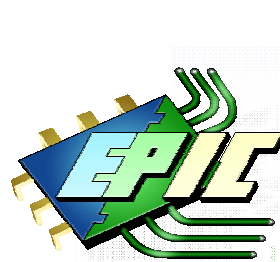
μ-LADAR



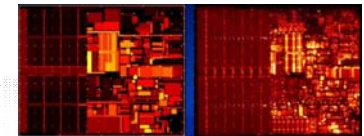
Montage



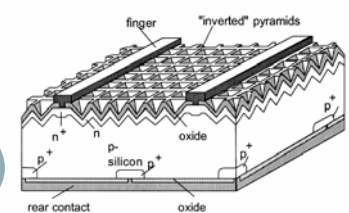
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Optical Buffer



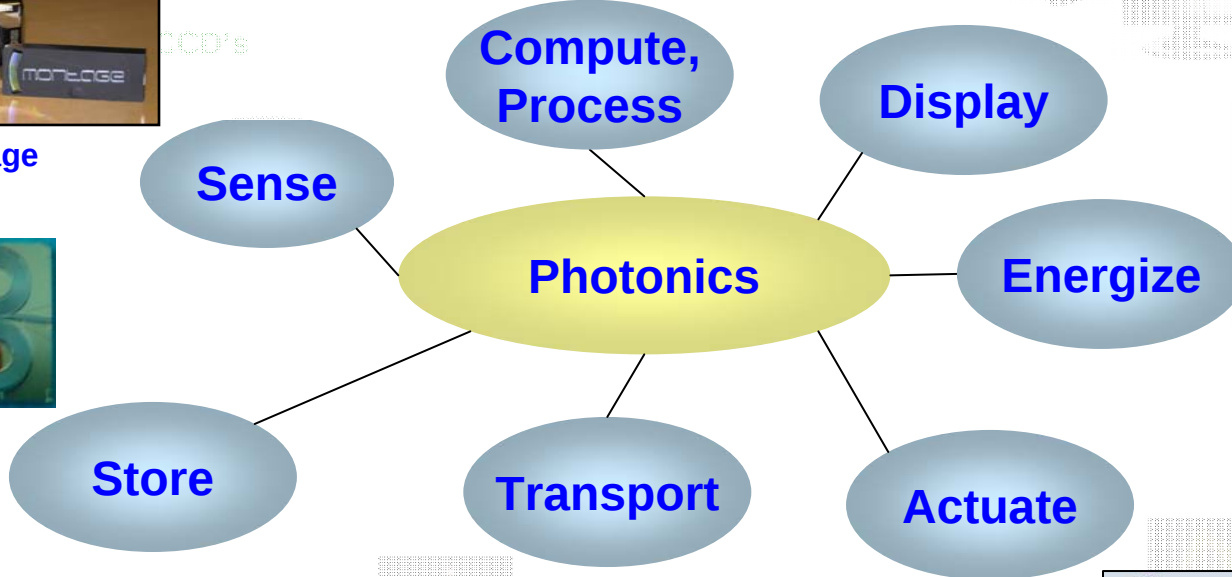
PhASER



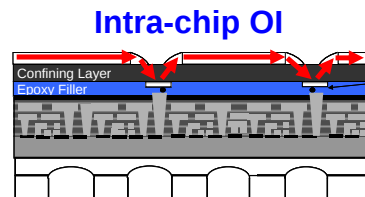
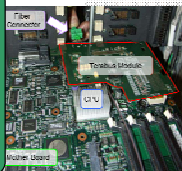
Chip-scale Energy
scavenging?



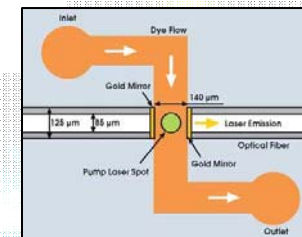
Chip scale solar cell



C201



Intra-chip OI



μ-opto-fluidics

Holographic Storage

Laser Welding



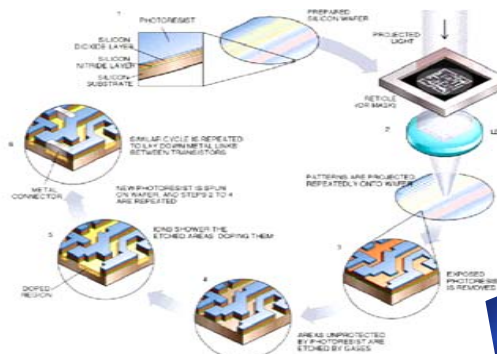
The PIC Payoff



Old: “finger-fab”
Photonics



New: “foundry-fab”
Photonics



Many Killer
Applications

Fab-less PIC
design

Technology
Scaling



The “light” side